S. PTO 1166	Subclass	SSUE CLASSIFICATION
09/99	Class	SSUE CLA

1	ノ	
	*	 

U.S. **UTILITY** Patent Application

, o	
O.I.P.E.	PATENT DATE
SCANNED TRO QASS	

PATENT NUMBER

	PLICATION NO. 09/991166	CONT/PRIOR D F	CLASS 438	SUBCLASS	ART UNIT	EXAMINER PLANTY
APPLICANTS	Chentsau Y Jens Hwans Yona Ko Se Oh	/ing			1-65	Vinh
TITLE	Method of metal etch	reducing process	particul	lates in a	plasma etc	ch chamber during a

ISSUING CLASSIFICATION					
ORIGINA	IAL		CROSS REFERENCE(S)		
CLASS	SUBCLASS	CLASS SUBCLASS (ONE SUBCLASS PER BLOCK)			
INTERNATIONA	L CLASSIFICATION				
	-				
<del></del>			Continued on Issue Slip Inside File Jacket		

TERMINAL DISCLAIMER	DRAWINGS			CLAIMS ALLOWED	
	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims	Print Claim for O.G.
The term of this patent		<u> </u>		NOTICE OF AL	LOWANCE MAILED
subsequent to (date) has been disclaimed.	(Assistant Examiner) (Date)		1		
The term of this patent shall not extend beyond the expiration date of U.S Patent. No.			·	ISS	UE FEE
				Amount Due	Date Paid
	(Primary Examiner) (Date)				
The terminalmonths of this patent have been disclaimed.			(Date)	ISSUE BA	TCH NUMBER
	(Legal instrum	ents Examiner)	(1989)	L	
WARNING: The information disclosed herein may be real Possession outside the U.S. Patent & Trades	stricted. Unauthorized mark Office is restricted	disclosure may be d to authorized emp	prohibited by the loyees and contract	United States Code Title ctors only.	35, Sections 122, 181 and 368
orm PTO-436A Rev. 6/99)			FILED WITH	: DISK (CRF)	FICHE CD-RO

(FACE)